UNITED STATES PATENT AND TRADEMARK OFFICE CERTIFICATE OF CORRECTION

Page 1 of 2

PATENT NO. : 7,384,984 B2

APPLICATION NO. : 10/732715 DATED : June 10, 2008

INVENTOR(S)

: Kevin M. Lewandowski

It is certified that error appears in the above-identified patent and that said Letters Patent is hereby corrected as shown below:

Title Page

Item [56], under "Other Publications", Line 5, delete "Oduin," and insert -- Odian, --, therefor.

Item [56], under "Other Publications", Line 8, delete "GIbov," and insert -- Gibov, --, therefor.

Item [56], under "Other Publications", Line 9, delete "Jerusaled," and insert -- Jerusalem, --, therefor.

Item [56], under "Other Publications", Line 16, delete "Havign" and insert -- Having --, therefor.

Column 13

Line 7, delete "but-they" and insert -- but they --, therefor.

Column 15

Line 23, delete "triimethylsilyl" and insert -- trimethylsilyl --, therefor.

Column 16

Line 1, delete "M,," and insert -- Mc, --, therefor.

Column 22

Line 54, delete "H. P." and insert -- H.P. --, therefor.

Column 23

Line 17, delete "M_wapproximately" and insert -- M_w approximately --, therefor.

Line 48, delete "(0.1 g)" and insert -- (0.1 g), --, therefor.

UNITED STATES PATENT AND TRADEMARK OFFICE **CERTIFICATE OF CORRECTION**

PATENT NO.

: 7,384,984 B2

Page 2 of 2

DATED

APPLICATION NO.: 10/732715 : June 10, 2008

INVENTOR(S)

: Kevin M. Lewandowski

It is certified that error appears in the above-identified patent and that said Letters Patent is hereby corrected as shown below:

Column 24

Line 13, delete "(10 g)" and insert -- (100g) --, therefor.

Line 28, delete "(10 g)" and insert -- (100g) --, therefor.

Column 25

Line 40, in claim 4, after "residual" insert -- monomer and solvent --.

Line 57, in claim 9, delete "oliogomer," and insert -- oligomer, --, therefor.

Column 27

Line 23, in claim 21, after "residual" insert -- monomer and solvent --.

Line 37, in claim 22, after "monomer" delete "units".

Signed and Sealed this

Twenty-sixth Day of May, 2009

JOHN DOLL Acting Director of the United States Patent and Trademark Office